Transparent Conducting Oxides (TCO) References

- Choudhary, R. J., et al., Pulsed-electron-beam deposition of transparent conducting SnO2 films and study of their properties. *Applied Physics Letters* 84, no. 9:1483-1485 (2004).
- Huang, L., et al., Properties of transparent conductive In2O3: Mo thin films deposited by Channel Spark Ablation. *Journal of Vacuum Science & Technology a* 23, no. 5:1350-1353 (2005).
- Porter, H. L., et al., Growth of ZnO films on C-plane (0001) sapphire by pulsed electron deposition (PED). *Materials Science And Engineering B-Solid State Materials For Advanced Technology* 119, no. 2:210-212 (2005).
- Yanwei H. et al., Investigation on structural, electrical and optical properties of tungstendoped tin oxide thin films. *Thin Solid Films* 518, 1892-1896 (2010).
- Ming Y. et al., Copper doped nickel oxide transparent p-type conductive thin films deposited by pulsed plasma deposition, *Thin Solid Films* (2010).
- Yanwei H. et al., Tungsten-doped tin oxide thin films prepared by pulsed plasma deposition, *Materials Characterization* 60, 415-419 (2009).